Appl. No. (to be assigned)
Prel. 'Amdt. filed concurrently
Applicant's Docket no. JP030020

## IN THE CLAIMS

Please amend the claims as follows:

Claim 1 (original): A method of manufacturing liquid crystal display device comprising the steps of:

forming an organic material film having projections and depressions, using a photo-embossing material, on an insulating film on an underlying electrode in a thin-film transistor of an active-matrix liquid crystal display device; exposing said insulating film in a contact-hole-forming-area

by reducing a thickness of said organic material film by a dry etching to said organic material film; and

forming a contact hole by a dry etching to the exposed insulating film.

Claim 2 (original): A method as claimed in claim 1, further comprising the steps of:

exposing said underlying electrode in forming said contact hole; and

contacting the exposed underlying electrode with a reflective electrode by forming said reflective electrode on the resulting structure.

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Claim 3 (currently amended): A method as claimed in claim 1 or 2, wherein said photo-embossing material is a material patternable by an exposing step and a baking step.

Claim 4 (original): A method as claimed in claim 3, wherein said organic material film is formed by exposing and baking said photo-embossing material in forming said organic material film.

Claim 5 (original): A method as claimed in claim 4, wherein a halftone mask or a diffraction mask is used in exposing.

Claim 6 (currently amended): A method as claimed in any one of claims 1 to 5, wherein the dry processes are performed from the step of forming said organic material film to the step of forming said contact hole.

Claim 7. (currently amended): A method as claimed in any one of claims 1—to 6, wherein the step of exposing said insulating film and the step of forming said contact hole are performed in a single apparatus.

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Claim 8 (currently amended): A method as claimed in any one of claims 1—to-7, wherein a dry etching process in the step of exposing said insulating film is performed in an Inductively Coupled Plasma mode or a reactive ion etching mode.

Claim 9 (currently amended): A method as claimed in any one of claims 1-to-8, wherein said liquid crystal display device is a reflective type of liquid crystal display device or a transflective type of liquid crystal display device.